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APPLICATION NO.	1	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/681,541		10/08/2003	Chao-Hsiung Wang	N1085-00223(N1280-00225)	80-00225) 7285	
8933	7590	01/10/2006		EXAMINER		
DUANE M	IORRIS,	LLP	ULLAH, ELIAS			
IP DEPARTMENT 30 SOUTH 17TH STREET				ART UNIT	PAPER NUMBER	
PHILADELPHIA, PA 19103-4196				2812		
			·	DATE MAILED: 01/10/2006	,	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	
		10/681,541	WANG ET AL.	
	Office Action Summary	Examiner	Art Unit	
		Elias Ullah	2812	
Period fo	The MAILING DATE of this communication app	pears on the cover sheet with the	correspondence address	
A SH WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPL' CHEVER IS LONGER, FROM THE MAILING Donsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. Depriod for reply is specified above, the maximum statutory period vire to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATIO 36(a). In no event, however, may a reply be till apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communicat (D (35 U.S.C. § 133).	
Status				
1)⊠	Responsive to communication(s) filed on <u>08 O</u>	ctober 2003.		
-		action is non-final.		
3)	Since this application is in condition for allowar	nce except for formal matters, pre	osecution as to the merits	is
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.	
Disposit	ion of Claims			
4)⊠ 5)□ 6)□ 7)□	Claim(s) 1-35 is/are pending in the application.  4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed.  Claim(s) is/are rejected.  Claim(s) is/are objected to.  Claim(s) 1-35 are subject to restriction and/or of	wn from consideration.		
Applicat	ion Papers			
10)	The specification is objected to by the Examine The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Ex	epted or b) objected to by the drawing(s) be held in abeyance. Se tion is required if the drawing(s) is ob	e 37 CFR 1.85(a). ejected to. See 37 CFR 1.121	
Priority (	under 35 U.S.C. § 119			
12) <u>□</u> a)	Acknowledgment is made of a claim for foreign All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureau See the attached detailed Office action for a list	s have been received. s have been received in Applicat rity documents have been receiv u (PCT Rule 17.2(a)).	ion No ed in this National Stage	
Attachmer	nt(s)			
1) Notice 2) Notice 3) Infor	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date	4) Interview Summar Paper No(s)/Mail D 5) Notice of Informal 6) Other:		

Application/Control Number: 10/681,541 Page 2

Art Unit: 2812

## **DETAILED ACTION**

## Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- I. Claims1-9, drawn to a process for transforming a part of a target semiconductor substrate to be a non-semiconductor material, classified in class 438, subclass 758+.
- II. Claims 10- 35, drawn to an apparatus classified in class 250, subclass 493+.

Inventions I and II are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In the instant case, the apparatus as claimed can be used to practice another and materially different process, such as a process which does not require that the semiconductor material thereon be transformed to be a non-semiconductor material. And the process as claimed can be practiced by another materially different apparatus, on by hand, such as an apparatus which does not require a mask set exposed to the high energy source and the electro-magnetic radiation source, the mask set having at least one mask with at least one alignment area and at least mask target area thereon, the mask target area passing more high energy particles than any other area of the mask.

Because these inventions are distinct for the reason given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Application/Control Number: 10/681,541 Page 3

Art Unit: 2812

Because these inventions are distinct for the reason give above and the search required for Group I is not for Group II, restriction for examination purposes as indicated is proper.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Elias Ullah whose telephone number is 571-272-1415. The examiner can normally be reached on 8-5PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, MICHAEL LEBENTRITT can be reached on (571)272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Elias Ullah Patent Examiner Art Unit 2812

**EMU** 

December 22, 2005